



The Determination of Residual Solvents in Pharmaceuticals Using the Agilent G1888 Network Headspace Sampler

Application

Pharmaceuticals

Author

Roger L. Firor
Agilent Technologies, Inc.
2850 Centerville Road
Wilmington, DE 19808-1610
USA

Abstract

The G1888 Network Headspace Sampler interfaced to 6890N gas chromatographs configured with either an FID or 5973 inert MSD were used for the determination of regulated residual solvents. Standard mixtures in water were used at various concentrations including levels below published acceptance guidelines to demonstrate system performance. Included were Class 1 and Class 2 solvents, according to the International Conference on Harmonization, and those listed in USP 467. Repeatability, inertness, and carryover reduction are improved compared to previous generation samplers, using the automated 70-sample G1888 with Siltek flow path. Integrated control and sequencing of the sampler is incorporated into the Agilent GC ChemStation through an add-on software module.

Introduction

Organic volatile impurities (OVIs) can result from the manufacture of active pharmaceuticals or other drug products. Many are used to enhance yields, improve crystallization, or increase solubility [1]. Other factors such as packaging, transportation, and storage can also impact the level of residual solvents. Gas chromatography (GC) coupled with static headspace sampling, acknowledged as an easy-to-use high-throughput analytical tool for the determination of low-level solvent impurities in drugs, can be found in nearly all Quality Control (QC) laboratories in pharmaceutical manufacturing facilities. Sample prep is relatively simple and the methodology is easily validated as per specific monographs.

General guidelines established by the International Conference on Harmonization (ICH) divide solvents into three classes [2]. The Class 1 solvents should not be used in pharmaceutical manufacture because of toxicity or environmental impact, while use of Class 2 solvents should be limited due to potential toxicity. Class 3 solvents are regarded as posing a lower risk to human health. Solvents listed in USP 467 include a subset of specific Class 1 and Class 2 solvents.

This application note will demonstrate the analysis and quantitation of Class 1 and Class 2 solvents. See Table 1 for a listing of residual solvents.



Agilent Technologies

Table 1A. Class 1 Solvents in Pharmaceutical Products - To Be Avoided [2]

| Solvent | Concentration limit (ppm) | Concern |
|-----------------------|----------------------------------|--------------------------------|
| Benzene | 2 | Carcinogen |
| Carbon tetrachloride | 4 | Toxic and environmental hazard |
| 1,2-Dichloroethane | 5 | Toxic |
| 1,1-Dichloroethene | 8 | Toxic |
| 1,1,1-Trichloroethane | 1500 | Environmental hazard |

Table 1B. Class 2 Solvents in Pharmaceutical Products [2]

| Solvent | Permissible daily exposure (ppm) (mg/day) | Concentration limit (ppm) |
|-----------------------|--|----------------------------------|
| Acetonitrile | 4.1 | 410 |
| Chlorobenzene | 3.6 | 360 |
| Chloroform | 0.6 | 60 |
| Cyclohexane | 38.8 | 3880 |
| 1,2-Dichloroethene | 18.7 | 1870 |
| Dichloromethane | 6.0 | 600 |
| 1,2-Dimethoxyethane | 1.0 | 100 |
| N,N-Dimethylacetamide | 10.9 | 1090 |
| N,N-Dimethylformamide | 8.8 | 880 |
| 1,4-Dioxane | 3.8 | 380 |
| 2-Ethoxyethanol | 1.6 | 160 |
| Ethyleneglycol | 6.2 | 620 |
| Formamide | 2.2 | 220 |
| Hexane | 2.9 | 290 |
| Methanol | 30.0 | 3000 |
| 2-Methoxyethanol | 0.5 | 50 |
| Methylbutyl ketone | 0.5 | 50 |
| Methylcyclohexane | 11.8 | 1180 |
| N-Methylpyrrolidone | 48.4 | 4840 |
| Nitromethane | 0.5 | 50 |
| Pyridine | 2.0 | 200 |
| Sulfolane | 1.6 | 160 |
| Tetralin | 1.0 | 100 |
| Toluene | 8.9 | 890 |
| 1,1,2-Trichloroethene | 0.8 | 80 |
| Xylene* | 21.7 | 2170 |

* Usually 60% m-xylene, 14% p-xylene, 9% o-xylene with 17% ethyl benzene.

Table 1C. Solvents in Pharmaceutical Products, According to USP 467

| Solvent | Concentration limit (ppm) |
|--------------------|----------------------------------|
| Methylene chloride | 600 |
| Chloroform | 60 |
| Benzene | 2 |
| Trichloroethylene | 80 |
| 1,4-dioxane | 380 |

Residual solvent and other contaminant levels, designated as safe, have trended downward in recent years as information about potential harmful effects of long-term and/or low-level exposures accumulate and as the detection sensitivity of analytical instrumentation improves. For example, based on new toxicity data, a 2003 change in the regulations for residual solvents stipulate a 10-fold reduction of the 1997 PDE (permitted daily exposure) and residual concentration limits for the solvent N-methylpyrrolidone [3]. It also reclassifies tetrahydrofuran from a Class 3 to a Class 2 category solvent with PDE and concentration limitations more restrictive than toluene [3]. Table 1B also lists PDE and concentration limits for Class 1 and Class 2 residual solvents in pharmaceutical products [4].

Experimental

Two systems are described in this work. The first, based on flame ionization detection is considered the system of choice for routine QC work, while the second system with mass selective detection provides unknown determination, possible quantitation of near-coeluting peaks, and solvent confirmation. Ten-milliliter headspace vials were used for all experiments containing 5 mL water as the matrix, with 1-g sodium sulfate added to assist with analyte extraction. The headspace sampler was equipped with a 1-mL sample loop. Since a sufficient flow must be maintained through the system to avoid excessive peak broadening, a split injection is used. A 2:1 split ratio is the lowest recommended with typical 0.53-mm id column flows.

Table 2. Instrument Conditions

| FID system | | 5973 inert system | |
|---------------------------------|---|---------------------------------|--------------------------------|
| 6890N GC | | 6890N GC | |
| Injection port | Volatiles interface | Injection port | Volatiles interface |
| Temperature | 160 °C | Temperature | 160 °C |
| Split ratio | 2:1 to 5:1 | Split ratio | 2:1 to 5:1 |
| Carrier gas | Helium | Carrier gas | Helium |
| Carrier flow | 9 mL/min | Inlet pressure | 2.7 psi |
| Detector | FID, 250 °C | Column flow | 1.7 mL/min |
| GC oven program | | GC oven program | |
| Initial temperature | 35 °C | Initial temperature | 35 °C |
| Initial time | 20 min | Initial time | 20 min |
| Rate | 25 °C/min | Rate | 20 °C/min |
| Final temperature | 250 °C | Final temperature | 250 °C |
| Final time | 15 min | Final time | 15 min |
| Columns | 30 m × 0.53 mm × 3 µm DB-624 30 m × 0.45 mm × 2.55 µm DB-624 | Column | 30 m × 0.32 mm × 1.8 µm DB-624 |
| G1888A Headspace Sampler | | G1888A Headspace Sampler | |
| | | Same settings as FID system | |
| | | 5973 inert | |
| Loop size | 1 mL | Scan | 30 to 200 amu, samples 2 |
| Vial pressure | 14.0 psig | SIM | 100 ms dwell |
| Headspace oven | 85 °C | Source temperature | 230 °C |
| Loop temp | 100 °C | Quad temperature | 150 °C |
| Transfer line temp | 120 °C | Tune | BFB.u |
| Equilibration time | 30 min, low shake | Standards | |
| GC Cycle time | 50 min | USP 467 | Restek #36228 |
| Pressurization | 0.15 min | | AccuStandard NF-467-R |
| Vent (loop fill) | 0.15 min | ICH Class 1 and 2 | Restek #36228 (Class 1) |
| Inject | 0.5 min | | #36229 (Class 2A) |
| | | | #36230 (Class 2B) |

Discussion

GC System

Most quality control labs in pharmaceutical manufacturing employ gas chromatography (GC) for the determination of residual solvents that are included in either USP 467 or in the more extensive list covered in ICH guidelines. Capillary GC based on the 624 phase (USP G43) is widely used for solvent separation. A different stationary phase such as DB-1701, DB-5, or DB-WAX (USP G16) can be used in specific methods when coelution is identified. Headspace sampling has many advantages over direct liquid injection including the avoidance of large water injections that can result in column degradation.

Table 3 lists concentrations and identifications of Class 1 and Class 2 solvents used to produce the chromatogram shown in Figure 1.

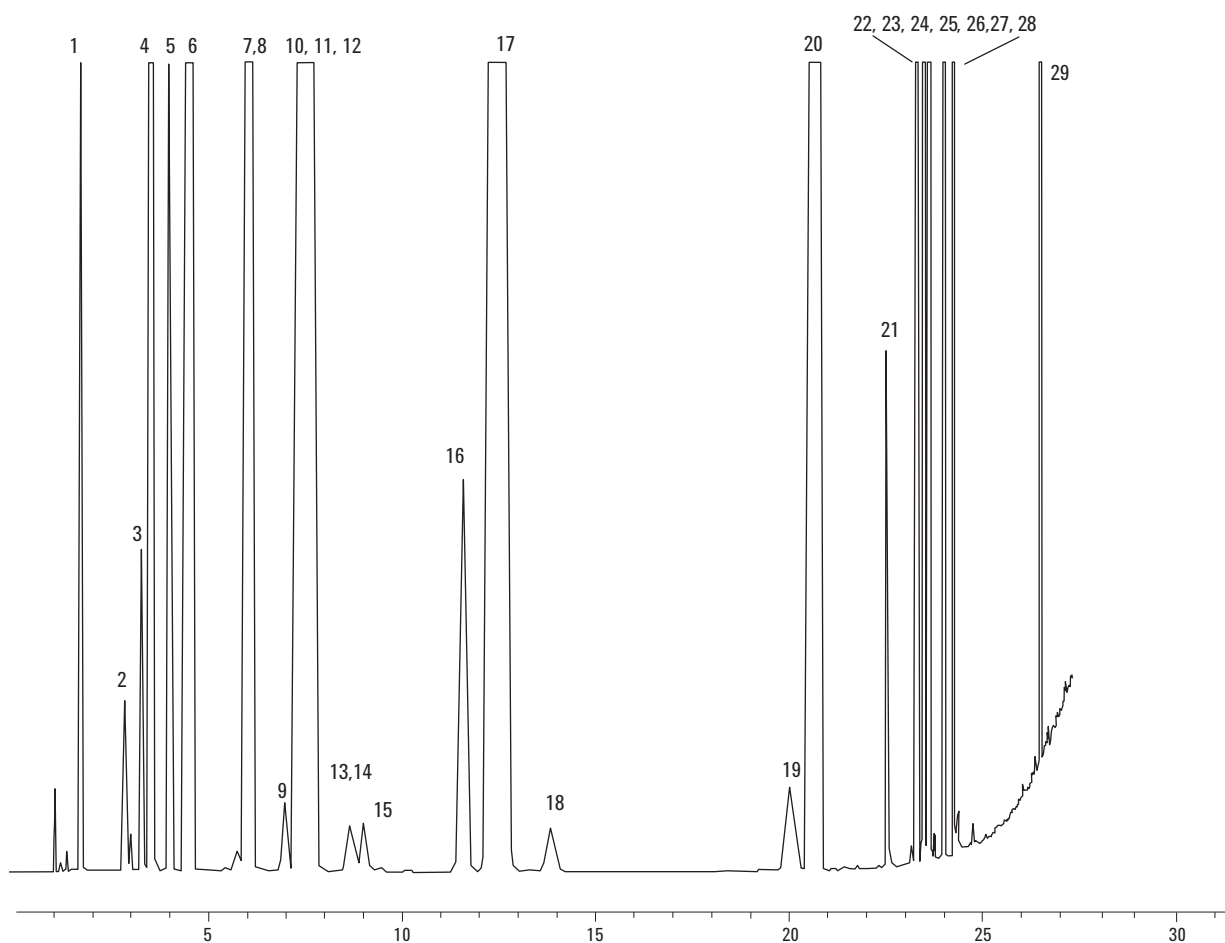


Figure 1. Class 1 and Class 2 residual solvents. G1888, 6890N with FID and volatiles interface.

These concentrations equal the guideline limits based on a 100-mg sample of the pharmaceutical dissolved in 5 mL. USP 467 solvents are shown in Figure 2 at concentrations below the required levels (10 μ L Restek std. #36228). Excellent signal-to-noise ratio is still achieved. Concentrations used throughout this work are defined as the analyte concentration present in the headspace vial prior to sampling.

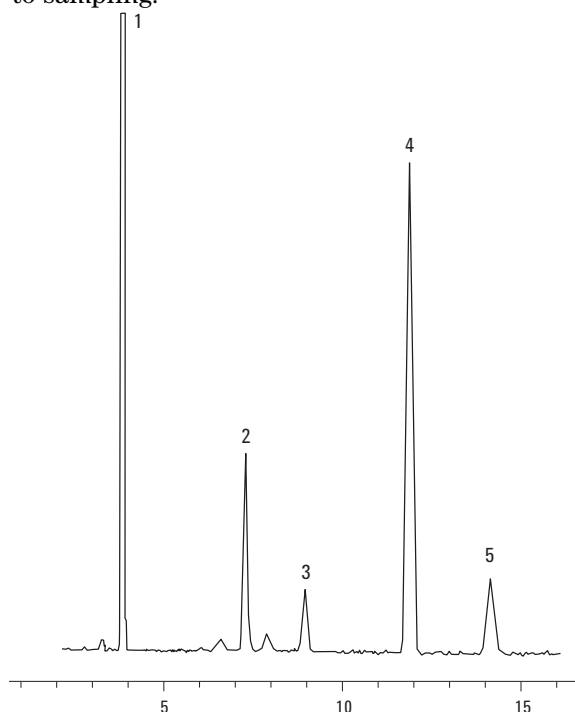


Figure 2. Identifications and concentrations: 1. Methylene chloride 1.2 μ g/mL, 2. Chloroform 0.12 μ g/mL, 3. Benzene 0.004 μ g/mL, 4. Trichloroethylene 0.16 μ g/mL, 5. 1,4-dioxane 0.76 μ g/mL.

Coelutions that occur on the DB-624 column under the chromatographic conditions and concentrations employed are listed in Table 4. Using the 30 m \times 0.45 mm \times 2.55 μ m DB-624 column, benzene and 1,2-dichloro-ethane can be resolved at a 35 $^{\circ}$ C oven temperature, as seen in Figure 3.

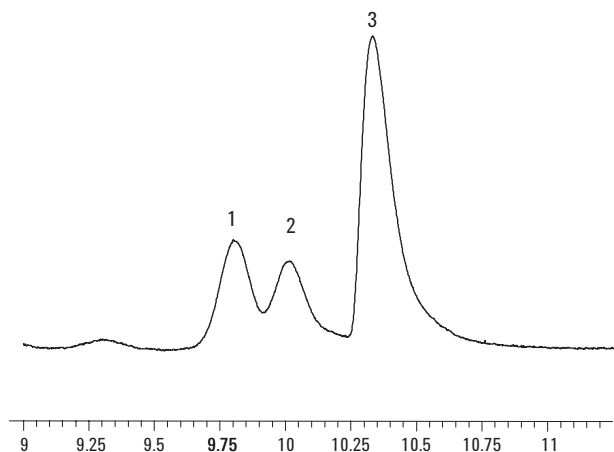


Figure 3. Resolution of benzene and 1,2 dichloroethane. Peak identifications: 1. benzene, 2. 1,2-dichloroethane, 3. 1,2-dimethoxyethane.

Calibration curves for selected solvents included in USP 467 are shown in Figure 4. Linear results are seen over a concentration range that extends well below recommended maximum concentrations. The concentration range is well within the linear dynamic range of the thick film 0.53 mm and 0.45-mm id columns.

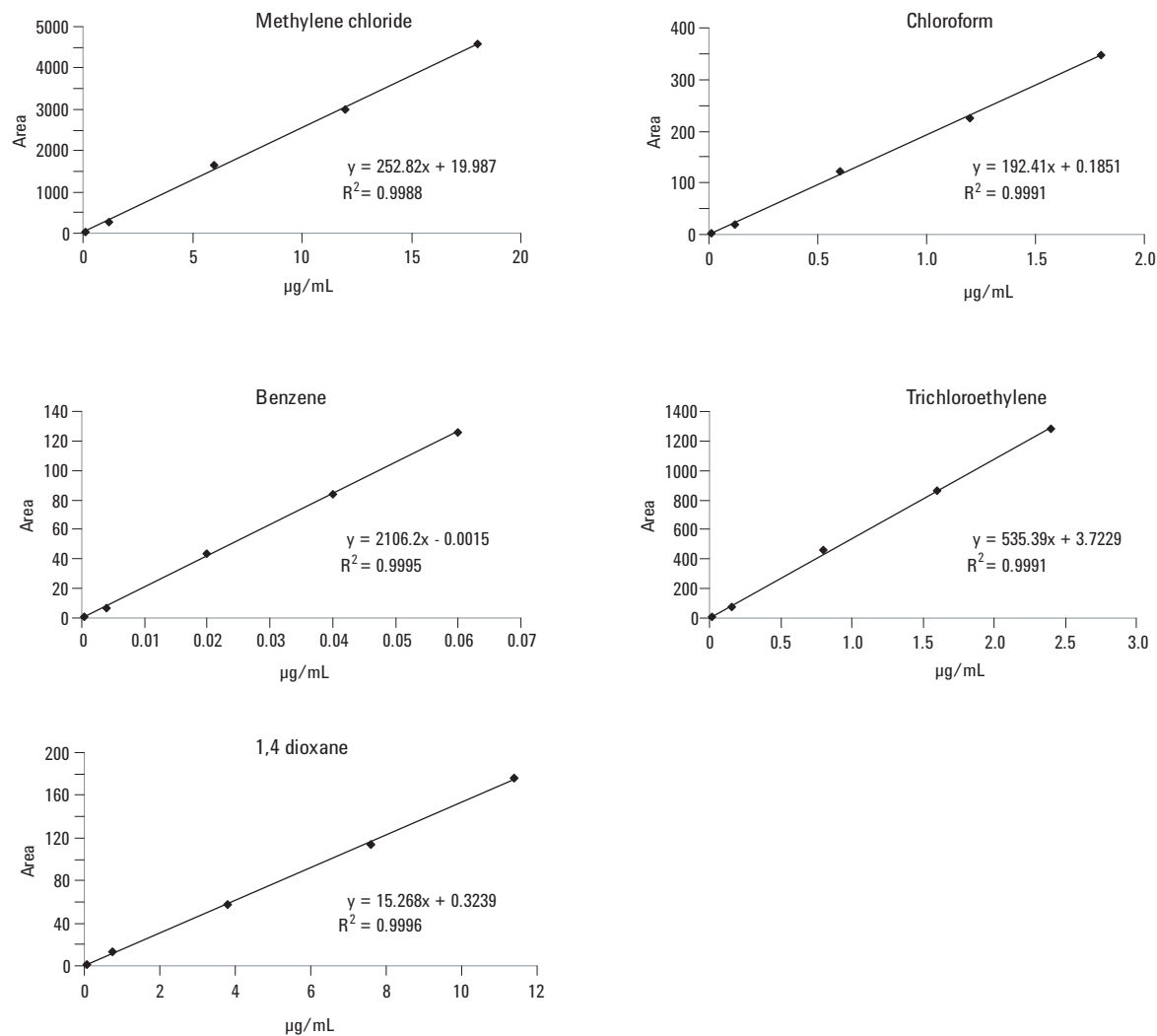


Figure 4. Calibration plots for selected solvents.

Headspace equilibration time is normally set at 60 min; however, in most cases 30 min is sufficient. Figure 5 illustrates an overlay of a 30- and 60-min headspace equilibration for a selected portion of the chromatogram (Class 1 and 2 solvents). Little overall difference is seen in the peak areas; although for some compounds 30-min equilibration produces marginally larger areas.

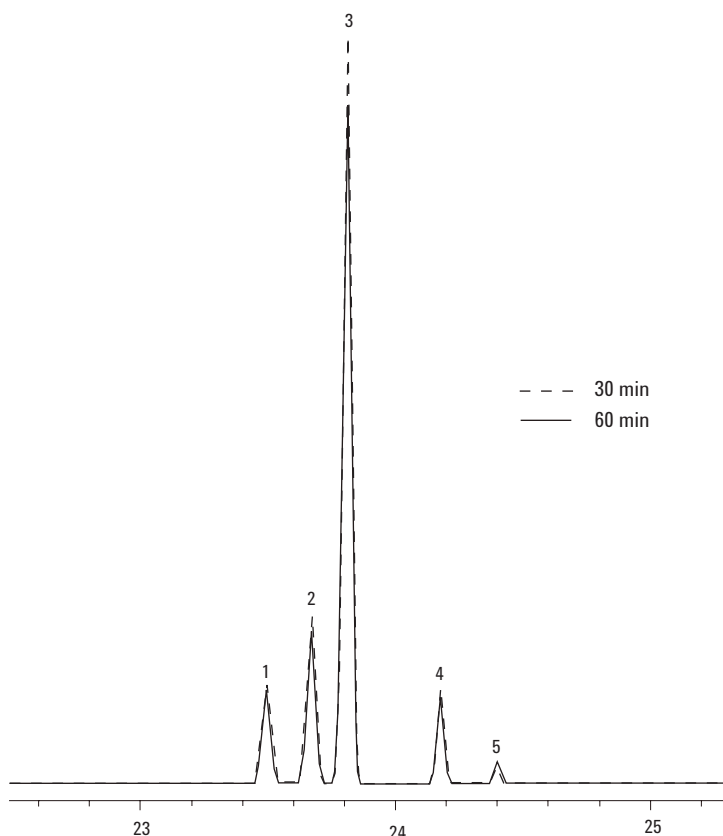


Figure 5. Overlay of selected compounds after 30- and 60-min headspace equilibration times. 1. Chlorobenzene, 2. Ethylbenzene and DMF, 3. m-xylene, p-xylene, 4. o-xylene, 5. N,N-dimethylacetamide.

Table 3. Class 1 and Class 2 Residual Solvent Concentrations*. Table ID Column Corresponds to Chromatogram Numbering

| Solvent | ID | Conc. (µg/mL) | Solvent | ID | Conc. (µg/mL) |
|------------------------|----|---------------|-----------------------|----|---------------|
| Methanol | 1 | 60 | Trichloroethylene | 16 | 1.6 |
| 1,1-Dichloroethane | 2 | 0.16 | Methyl cyclohexane | 17 | 236 |
| Acetonitrile | 3 | 8.2 | 1,4-Dioxane | 18 | 7.6 |
| Methylene chloride | 4 | 12 | Pyridine | 19 | 4 |
| Hexane | 6 | 5.1 | Toluene | 20 | 17.8 |
| cis-1,2-dichloroethane | 7 | 37.4 | 2-Hexanone | 21 | 1 |
| Nitrobenzene | 8 | 1 | Chlorobenzene | 22 | 7.6 |
| Chloroform | 9 | 1.2 | Ethylbenzene | 23 | 7.38 |
| Carbon tetrachloride | 10 | 0.08 | N,N-dimethylformamide | 24 | 17.6 |
| Cyclohexane | 11 | 77.6 | m-xylene | 25 | 26.04 |
| 1,1,1-Trichloroethane | 12 | 30 | p-xylene | 26 | 6.08 |
| Benzene | 13 | 0.04 | o-xylene | 27 | 3.9 |
| 1,2-Dichloroethane | 14 | 0.1 | N,N-dimethylacetamide | 28 | 21.8 |
| 1,2-Dimethoxyethane | 15 | 2 | Tetraline | 29 | 2 |

*Concentrations shown are headspace vial solution concentrations prior to sampling. Peak 5 (*trans* 1,2 dichloroethane) is not listed in the table as a Class 1 or Class 2 solvent.

Table 4. Coelutions on 0.53-mm id DB-624

| Coelution group | Solvents |
|-----------------|---|
| 1 (partial) | Benzene, 1,2 dichloroethane |
| 2 | Nitrobenzene, <i>cis</i> -1,2 dichloroethene |
| 3 | Carbon tetrachloride, Cyclohexane, 1,1,1- trichloroethane** |
| 4 | Ethylbenzene, DMF |
| 5 | m-xylene, p-xylene |

* Trichloroethane will separate from CCl₄ in absence of cyclohexane

+ Figure 6 shows separation on a 30 m x 0.45 mm x 2.55 µm DB-624 Agilent part no.124-1334.

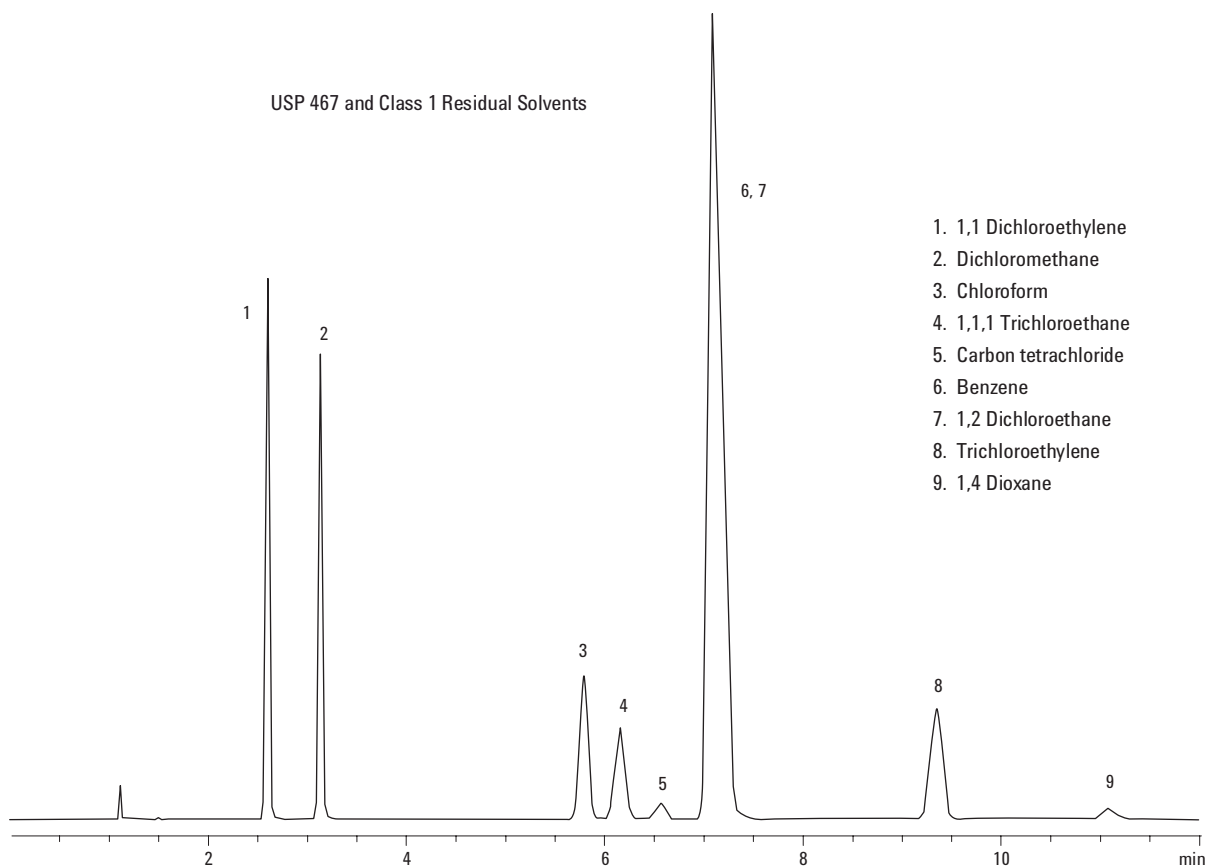


Figure 6. USP 467 and Class 1 solvents at 1 ppm each on the 30 m x 0.45 mm x 2.55 µm DB-624 column. Starting GC oven temperature was 40 °C.

MSD System

A TIC of Class 1 and Class 2 solvents produced with a G1888/6890N/5973 inert system is shown in Figure 7.

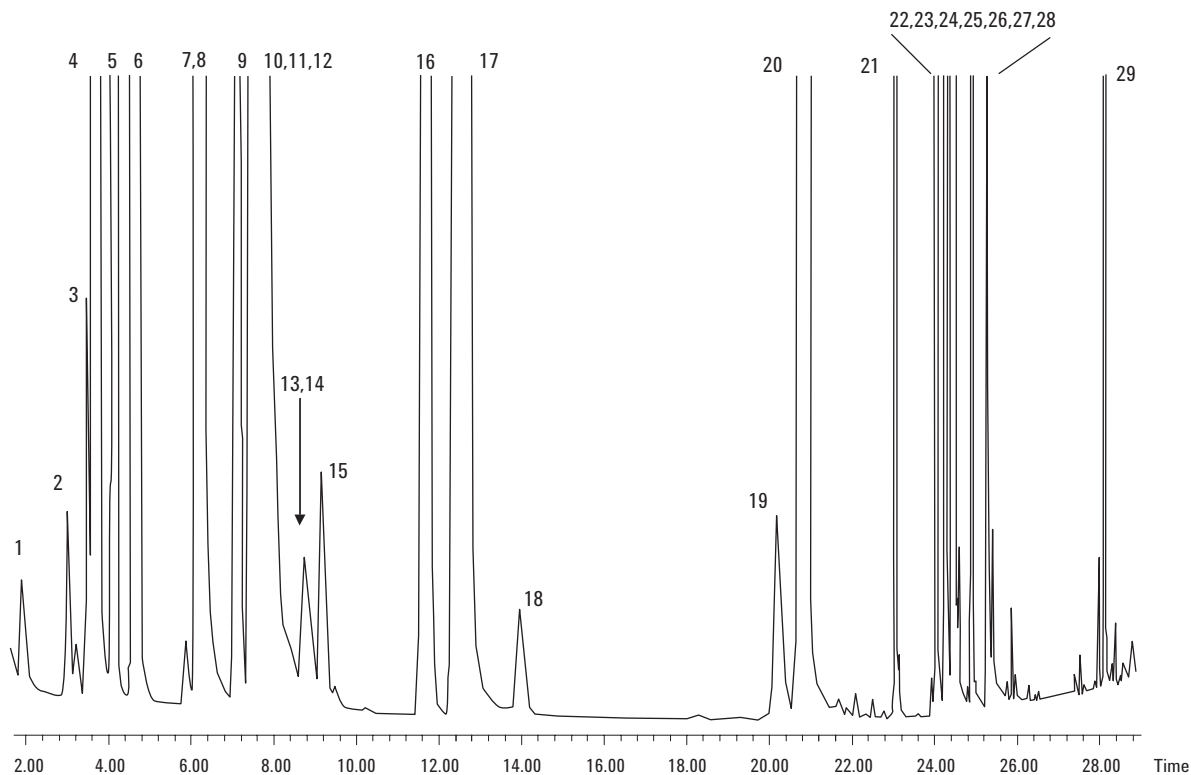


Figure 7. TIC of Class 1 and Class 2 solvents. See Table 3 for compound identifications.

Analyte solution concentrations and peak identifications are as indicated in Table 3. Gas chromatography/mass spectrometry (GC/MS) offers an alternative methodology to flame ionization detection (FID) that can be useful to solve coelution problems or identify unknowns. Also, excellent sensitivity and selectivity can be achieved in Selected Ion Monitoring (SIM) mode, which may be useful for drug manufacturing process development to identify and quantify trace impurities.

Carryover

In practice, nonaqueous solvents are commonly used in testing since extraction of many common solvents used in pharmaceutical manufacturing are not water soluble. Some common solvents include DMA (N,N-dimethylacetamide), DMSO, pyridine, and DMI (1,3-Dimethyl-2-imidazolidinone). Because many of the solvents used are high boiling, the possibility of headspace carryover exists. Improvements in the thermal zone temperature uniformity in the G1888 reduce the condensation of high-boiling materials in various flow path lines and vent valve.

The G1888 incorporates a new feature that allows users to program the vent purge time, labeled “Sequence Vent Purge” in the advanced functions menu. This represents the time interval when the vent line is purged as a post injection event. The default time of 30 seconds can be increased up to an approximate maximum of the cycle time. For the carryover experiments in this work, a vent purge time of 20 min was used to further reduce the possibility of solvent carryover.

One hundred microliters of pure solvent was introduced into 10-mL vials. Larger amounts of solvent will not result in an increase in the amount injected. A 10-vial sequence was set up with alternating solvent and water blank vials using the chromatographic program shown in the experimental section. This test was performed for pyridine, DMSO, and DMA. For all three solvents, carryover ($[\text{amount solvent area from blank vial} / \text{solvent area from solvent vial}] \times 100$) was under 0.006%. In addition, the solvent areas for all blanks had $\pm 3\%$ RSDs, indicating an absence of trending. As an additional carryover check, 10 consecutive vials of DMA (100 μL per 10-mL vial) were run at a Headspace oven temperature of 100 °C. These were followed by two water blanks. The first blank showed carryover of 0.004% and the second 0.001%.

One of the most effective solvent systems used today by pharmaceutical companies is DMI with a boiling point of 225 °C. Table 5 lists the system set points used in a carryover test with this solvent. Alternating vials of DMI and water blank were run in a headspace sequence. Results are shown in Figure 8.

The large concentration of DMI overloads the column and leads to some inconsistency in areas, however, it is not a concern given the purpose of this test. Measured carryover is under 0.003%.

Table 5. Setting Used for DMI Carryover Test

| | |
|---------------------|---|
| Headspace oven | 220 °C |
| Loop | 250 °C |
| Transfer line | 250 °C |
| Vial eq. time | 30 min |
| Sequence vent purge | 20 min |
| Sample | 100- μL DMI in 10-mL vial |
| Blanks | 5- μL water in 10-mL vial |
| Volatiles interface | 250 °C |
| Split ratio | 10:1 |
| Oven program | 35 °C (0 min) to 260 °C (15 min) at 25 °C/min |

To check for carryover of the actual analytes, a test scheme similar to that used for the pure solvents was chosen. One hundred microliters of the USP 467 standard (Restek # 36007) was placed in 5-mL water/1 g Na_2SO_4 . These vials were alternated with pure water blanks in a 10-vial sequence at 85 °C equilibration temperature. No measurable area for the analytes could be integrated in any of the runs.

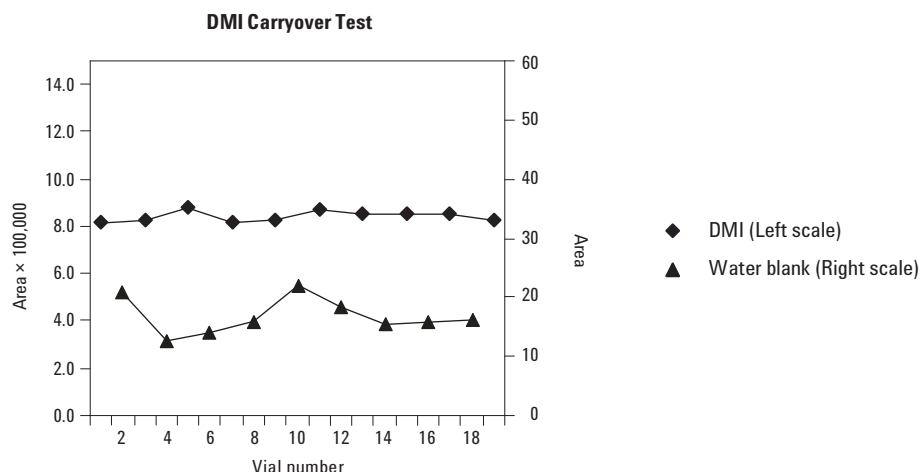


Figure 8. DMI carryover results.

Conclusions

Manufacturers of pharmaceuticals must ensure that residual solvents, OVIs, and related contaminants are not present in their products, or are present below levels stipulated as safe by regulation. One of the impediments to accurate determination of impurities at very low levels is the tendency for analyte interaction and/or reaction with the internal surfaces of the instrument sample path. To eliminate this problem, a new inert headspace sampler, the G1888 system was developed. This instrument possesses a nonreactive, nonadsorptive sample flow path from the point of injection through detection. This significantly reduces carry-over, a common problem with older instrumentation. High temperature heated zones extend the choice of solvent systems that can be used. When coupled to the 5973 inert MSD, which uses a solid inert source, superior results are obtained when the need for unknown identification or confirmation is required. Analytical results obtained for broad classes of solvents, used in medicinal products by the G1888 Headspace Sampler systems, described in this application show reduced carry-over, excellent detection sensitivity, and good linear response over the ppm to ppb range.

The methods and procedures outlined in this work illustrate potential approaches to the analysis of residual solvents. Laboratories should perform system suitability studies and validate their methods according to ICH or USP guidelines.

References

1. Anil M. Dwivedi, Residual Solvent Analysis in Pharmaceuticals, (Nov., 2002) *Pharmaceutical Technology*, 42-46.
2. Guidance for Industry, Q3C Impurities: Residual Solvents, U.S. Department of Health and Human Services, FDA, Center for Drug Evaluation and Research (CDER), Center for Biologics Evaluation and Research (CBER) Dec. 1997, ICH.
3. Revised PDEs for NMP and THF, Federal Register, 68, (219), Nov. 2003, Notices, 64353.
4. Limits of Residual Solvents, Federal Register, 62, (247), Dec. 1997, Notices 67380-67381.

For More Information

For more information on our products and services, visit our Web site at www.agilent.com/chem.

Agilent shall not be liable for errors contained herein or for incidental or consequential damages in connection with the furnishing, performance, or use of this material.

Information, descriptions, and specifications in this publication are subject to change without notice.

© Agilent Technologies, Inc. 2004

Printed in the USA
June 21, 2004
5989-1263EN



Agilent Technologies